Supporting Information

Controllable crumpling of N-doped graphene induced by capillary force resistance

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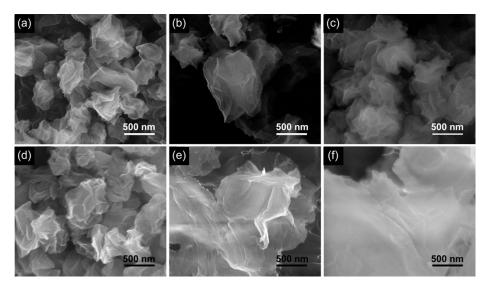


Fig. S1 SEM images of (a) un-WG, (b) un-1U-WG, (c) un-5U-WG, (d) un-10U-WG, (e) un-50U-WG, (f) un-100U-WG.

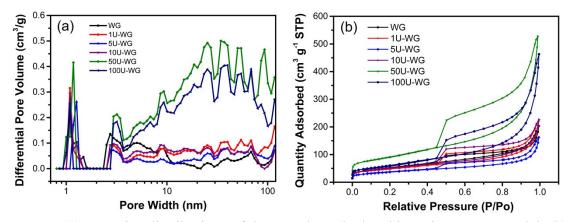


Fig. S2 (a) Pore size distributions of the samples calculated by using a DFT model; (b) Nitrogen adsorption/desorption isotherms of the samples.

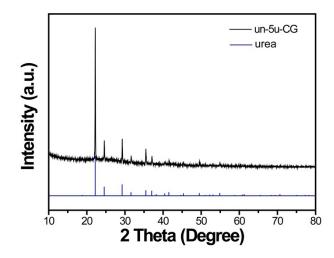


Fig. S3 XRD pattern of un-5U-WG.

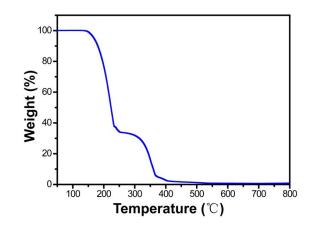


Fig. S4 The TGA curve of urea

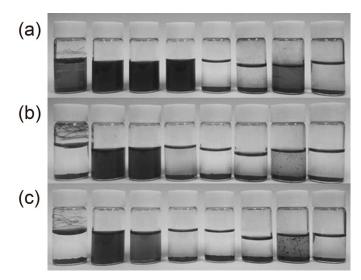


Fig. S5 The dispersibility of (a) 5U-WG, (b) 50U-WG, and (c) 100U-WG in different solvents after being stayed for 120 hour. (From left to right: water, N-methyl pyrrolidone, dimethyl amide, acetone, ethanol, benzene, chloroform and cyclohexane)